

Electronic Supplementary Information:

**Effects of Ambient Gas on Cold Atmospheric Plasma Discharge in the
Decomposition of Trifluoromethane**

Duc Ba Nguyen^a and Won Gyu Lee^{a†}

a) Department of Chemical Engineering, Kangwon National University,
Chuncheon, Kangwon, 24341, Republic of Korea

†) W. G. Lee. E-mail: wglee@kangwon.ac.kr

**S1. Record and measure of electrical power by an oscilloscope (Tektronix
TDS2012B, 2 channels)**

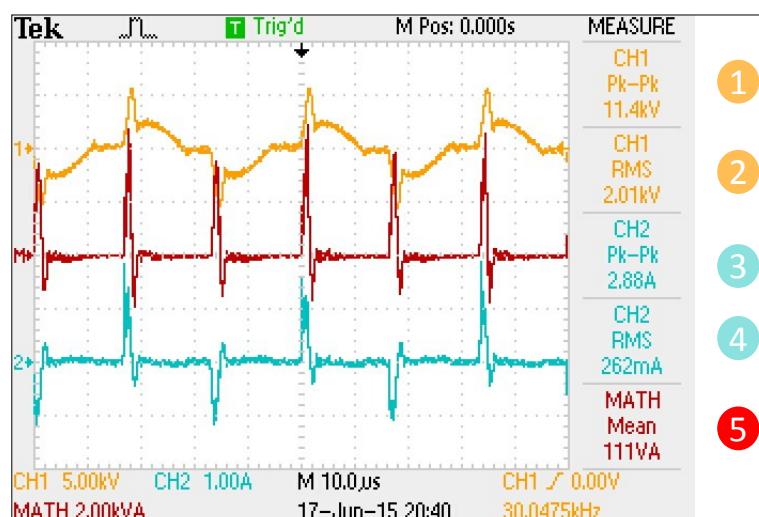


Fig. S1. Electrical waveforms of AC pulse power supplied and five parameter measurements: 1= applied voltage waveform, 2= total current waveform, M= active power, M1= peak to peak of voltage, M2= root mean square of applied voltage, M3= peak to peak of current, M4= root mean square of total current, M5= mean of active power (applied voltage = 6.0 kVp; frequency = 30 kHz total; flow rate = 1000 ml/min; CHF₃/O₂/N₂= 2/10/988 ml/min).

S2. Comparison of the phase angle between voltage and current for Ar and He as dilution gases

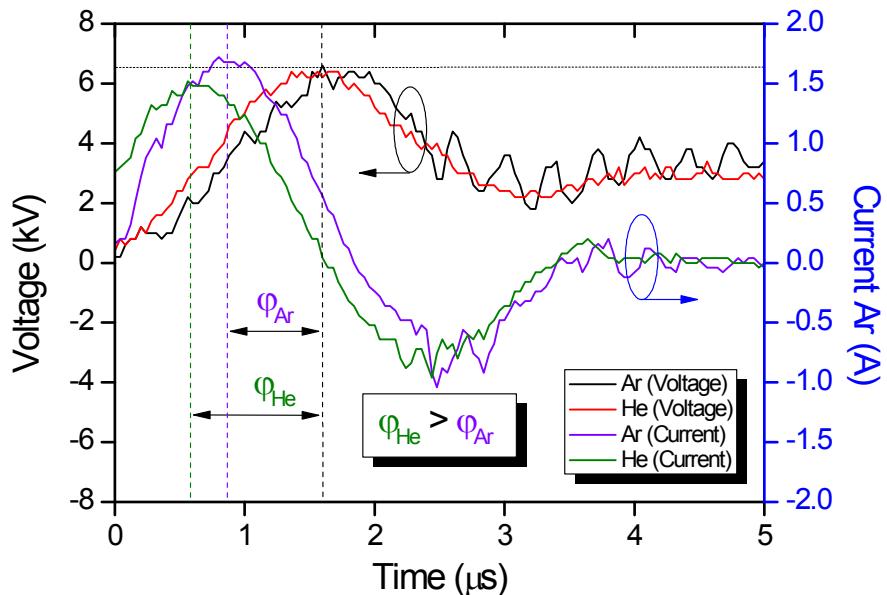


Fig. S2. Diagram of the phase angles between voltage and current for Ar and He as dilution gases (flow rate of CHF_3 , O_2 and total flow rate 2, 10 and 1000 ml/min, respectively; frequency= 30 kHz; applied voltage= 6.5 kVp).

S3. Identification of spectra of plasma discharges with the changing composition of the feed gas

Although there was an absence of N₂ in the feed gases with Ar or He dilution, these spectra present N₂ lines in the second positive system (C³Π_u → B³Π_g). A possible explanation for this might be that there was an N₂ contaminant in our plasma system under these conditions. This phenomenon also presented in the previous reports.^{1, 2}

All spectra have a high intensity of the emission line of gas dilution:

Ar dilution gas: from 680 to 1000 nm (Ar I)

He dilution gas: from 380 to 850 nm (He I)

N₂ dilution gas: from 300 to 500 nm (second positive system, C³Π_u → B³Π_g)

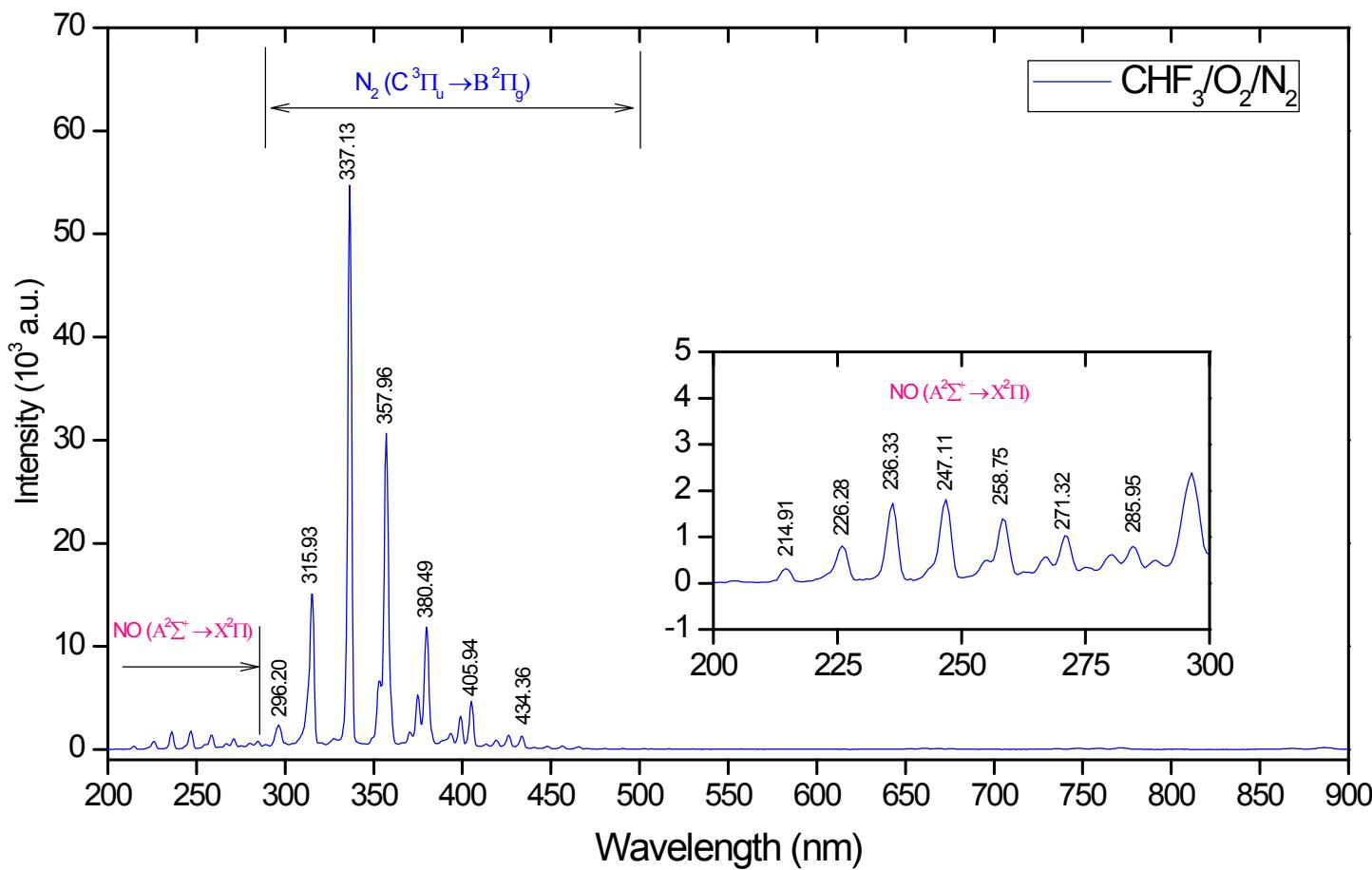


Fig. S3. Emission spectrum of $\text{CHF}_3/\text{O}_2/\text{N}_2$ plasma in a dielectric barrier discharge at atmospheric pressure
 (flow rate of $\text{CHF}_3/\text{O}_2/\text{N}_2 = 2/10/988$ ml/min; frequency= 30 kHz; active power= 60 W).

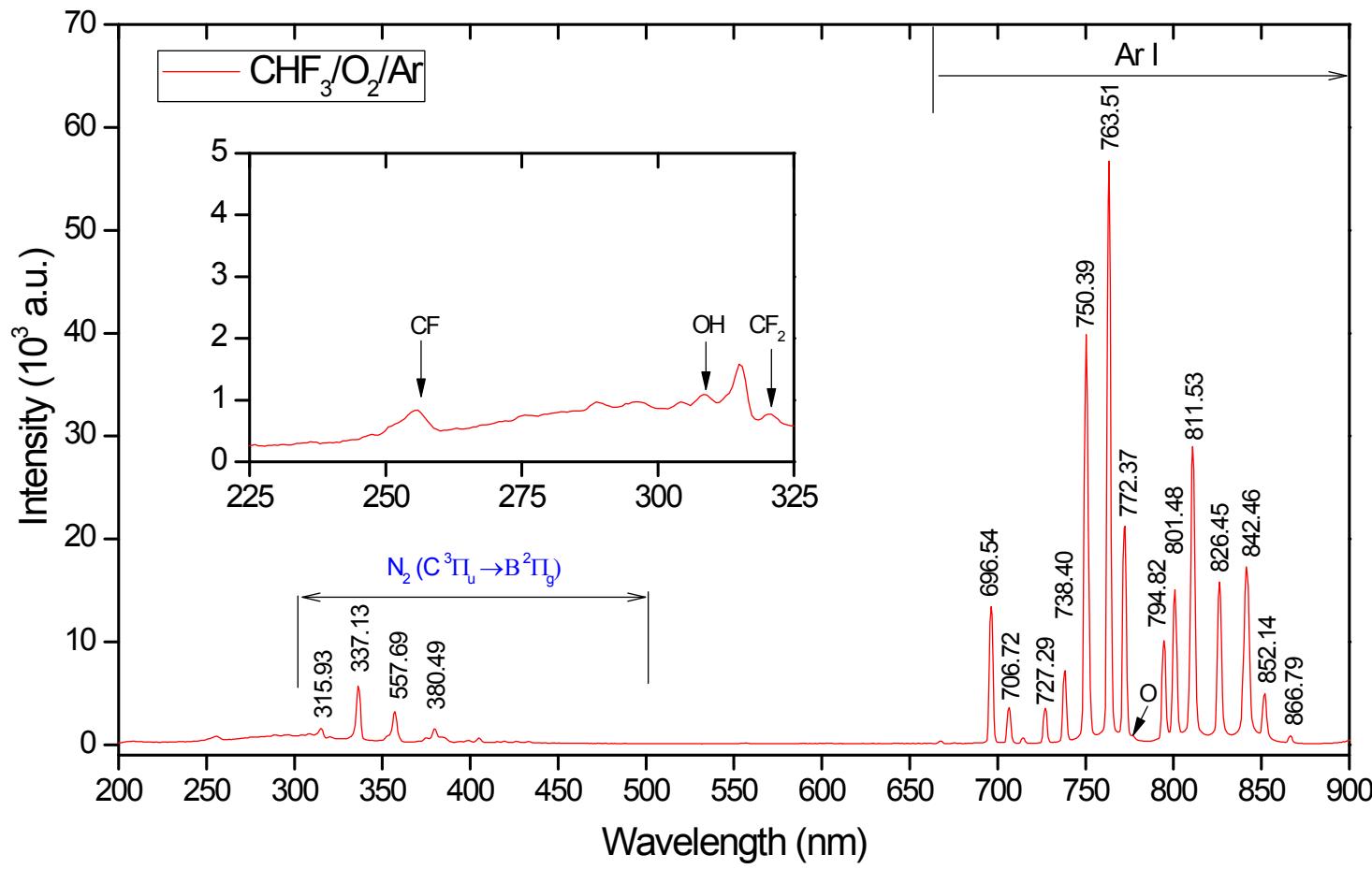


Fig. S4. Emission spectrum of $\text{CHF}_3/\text{O}_2/\text{Ar}$ plasma in a dielectric barrier discharge at atmospheric pressure
 (flow rate of $\text{CHF}_3/\text{O}_2/\text{Ar} = 2/10/988$ ml/min; frequency= 30 kHz; active power= 60 W).

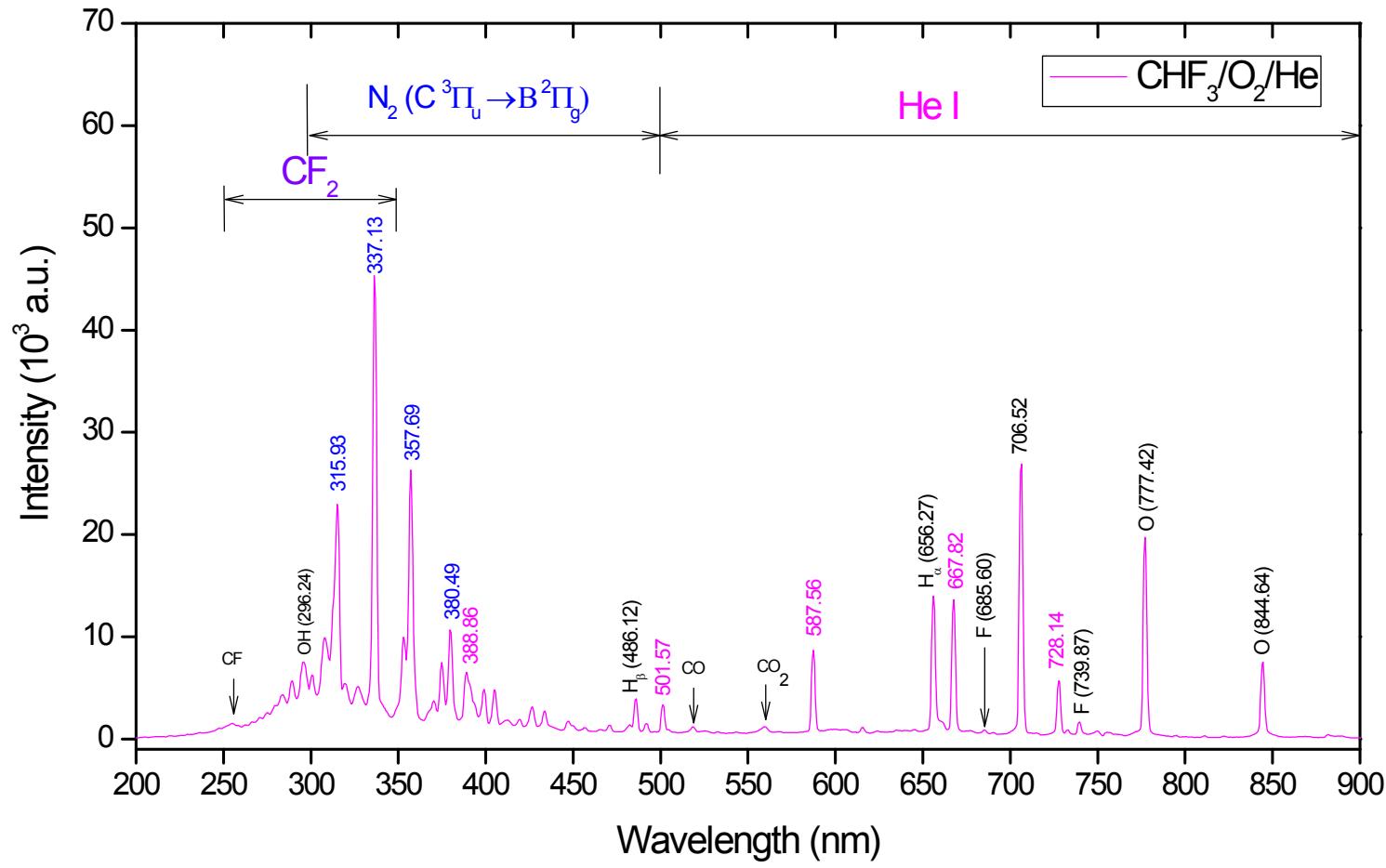


Fig. S5. Emission spectrum of $\text{CHF}_3/\text{O}_2/\text{He}$ plasma in a dielectric barrier discharge at atmospheric pressure
(flow rate of $\text{CHF}_3/\text{O}_2/\text{He} = 2/10/988$ ml/min; frequency= 30 kHz; active power= 60 W).

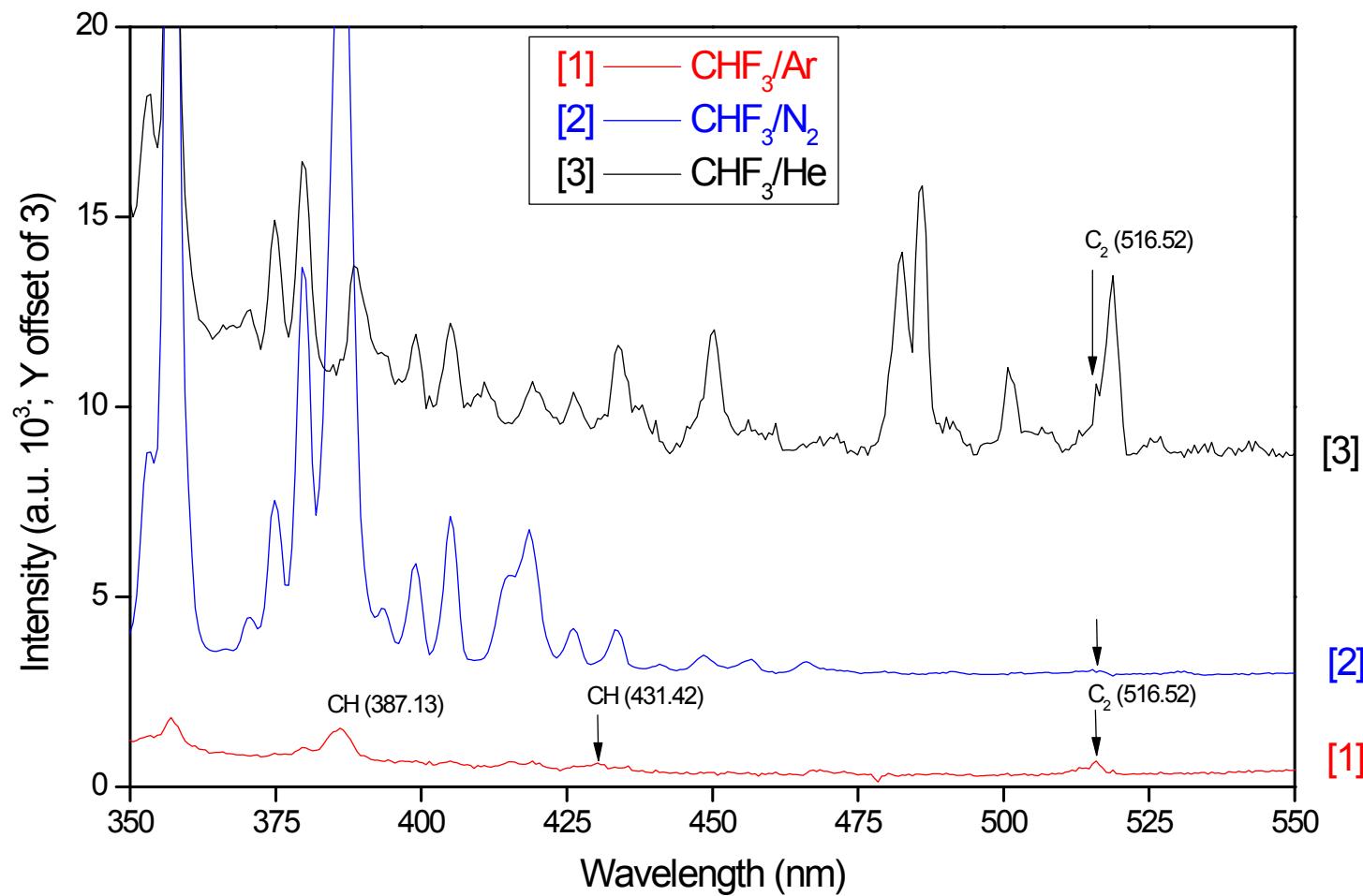


Fig. S6. Emission spectrum of CHF_3/X plasma in a dielectric barrier discharge at atmospheric pressure
(flow rate of $\text{CHF}_3/\text{X} = 8/988 \text{ ml/min}$, X stands for Ar, He or N_2 ; frequency= 30 kHz; active power= 60 W).

S4. Possible chemical reactions for the CHF₃ decompositions in the atmospheric plasma

Possible chemical reactions in plasma discharge were categorized into several groups by the reactants, as shown below. In each group of reactants, the kinetics of the chemical reactions are flowing largest to smallest at a temperature around 300 K. However, several rate constants of chemical reaction were recorded at high temperature because we did not find the rate constant of chemical reaction at the low temperature in the chemical kinetics database.³

The electron-impact reaction dissociated radicals or gas molecules. The kinetics of these reactions depended on electron energy. This can be described by an electron-impact cross section (σ).^{4, 5} The kinetics of the reaction between excited species (M) with radicals and gases molecules also depend on the energy of the excited species.

Chemical Reaction	Rate Constant		Ref.
	k (cm ³ /molecule s)	T (K)	
CHF₃ Reactant			
CHF ₃ + e/M → Products	σ (*)		5
CHF ₃ + ·F → ·CF ₃ + HF	1.56E-13	300	6
CHF ₃ + CF ₃ O → CF ₃ OH + ·CF ₃	5.99E-16	296	7
CHF ₃ + ·OH → ·CF ₃ + H ₂ O	3.06E-16	300	8
CHF ₃ + H· → H ₂ + ·CF ₃	7.36E-19	300	9
CHF ₃ → ·CF ₂ + HF	1.70E-19	1150	10
CHF ₃ + O· → ·CF ₃ + ·OH	9.89E-20	298	11
CHF ₃ + ·CF ₂ → ·CF ₃ + ·CHF ₂	4.62E-21	973	12
CHF ₃ + H· → ·CHF ₂ + HF	4.26E-40	300	13
CHF ₃ + H· → CH ₂ F ₂ + ·F	8.49E-58	300	13
·CF₃ Reactant			
·CF ₃ + e/M → Products	σ		5
·CF ₃ + ·CHF ₂ → CHF ₃ + ·CF ₂	8.79E-02	300	14
·CF ₃ + O· → COF ₂ + ·F	3.32E-11	298	15
·CF ₃ + NO → CF ₃ NO	2.01E-11	253-373	16
·CF ₃ + H· → ·CF ₂ + HF	9.10E-11	298	17
·CF ₃ + ·OH → COF ₂ + HF	2.61E-11	300	8
·CF ₃ + NO ₂ → NO + CF ₃ O	2.51E-11	300	18
·CF ₃ + N → Other Products + ·F	1.79E-11	293	19
·CF ₃ + NO ₂ → COF ₂ + FNO	1.53E-11	298	20
·CF ₃ + ·CF ₃ → C ₂ F ₆	1.30E-11	300	21
·CF ₃ + FCO → CF ₃ COF	6.91E-12	298	22
·CF ₃ + ·CF ₂ → C ₂ F ₅	6.42E-12	940	23
·CF ₃ + ·CF ₃ → Products	1.80E-12	290	24
·CF ₃ + O ₃ → O ₂ + CF ₃ O	9.30E-13	298	25
·CF ₃ + F ₂ → CF ₄ + ·F	6.60E-14	300	26
·CF ₃ + O ₂ → O· + CF ₃ O	2.93E-17	700	27
·CF ₃ → ·CF ₂ + ·F	1.91E-17	1600	28
·CF ₃ + H ₂ → CHF ₃ + H·	1.73E-18	350	29
·CF ₃ + N ₂ O → N ₂ + CF ₃ O	2.78E-20	589	30
·CF ₃ + ·F → CF ₄	1.47E-28	290	24

Chemical Reaction	Rate Constant		Ref.
	k (cm ³ /molecule s)	T (K)	
·CF ₃ + O ₂ → CF ₃ O ₂ (n=3)	2.93E-29	300	31
·CF ₃ + O ₂ + M → M + CF ₃ O ₂	1.90E-29	300	32
·CF ₃ + O· → CF ₃ O			33
·CF ₃ + H ₂ O → CHF ₃ + ·OH			34
·CHF ₂ Reactant			
·CHF ₂ + e/M → Products	σ		5
·CHF ₂ + H· → HF + ·CHF	1.25E+00	298	35
·CHF ₂ + ·CHF ₂ → CH ₂ F ₂ + ·CF ₂	1.30E-01	300-400	36
·CHF ₂ + H· → H ₂ + ·CF ₂	3.32E-11	600-1400	37
·CHF ₂ + O· → COF ₂ + H·	1.66E-11	600-700	37
·CHF ₂ + H ₂ → CH ₂ F ₂ + H·	6.93E-20	300	9
CO + ·CHF ₂ → FC≡CF + ·OH			38
CO + ·CHF ₂ → Products			38
CO + ·CHF ₂ → CHF ₂ CO			38
CO + ·CHF ₂ → CFCFOH			38
CO + ·CHF ₂ → CF ₂ CHO			38
CO + ·CHF ₂ → CF ₂ COH			38
·CF ₂ Reactant			
·CF ₂ + e/M → Products	σ		5
·CF ₂ + ·OH → Products	4.98E-11	1800	39
·CF ₂ + ·F → ·CF ₃	4.15E-11	298	40
·CF ₂ + O· → FCO + ·F	4.07E-11	2000-2430	41
·CF ₂ + H· → CF + HF	3.90E-11	298	17
·CF ₂ + H· → Products	3.32E-11	1800	39
·CF ₂ + ·OH → COF ₂ + H·	2.06E-11	300	42
·CF ₂ + O· → Products	1.66E-11	298	15
·CF ₂ + N → Products	7.21E-12	293	43
·CF ₂ + ·CF ₂ → C ₂ F ₄	3.70E-14	300	44
·CF ₂ + NO → CF ₂ NO	1.52E-14	1600	45
·CF ₂ + NO ₂ → COF ₂ + NO	7.52E-15	298	46
·CF ₂ + O ₂ → Other Products + CO	6.42E-15	1200	47
·CF ₂ + F ₂ → ·CF ₃ + ·F	2.01E-15	295	48

Chemical Reaction	Rate Constant		Ref.
	k (cm ³ /molecule s)	T (K)	
·CF ₂ + N ₂ O → Products	8.30E-16	298	46
·CF ₂ + O ₂ → COF ₂ + O·	4.72E-16	1200	49
·CF ₂ + O ₂ → Products	8.30E-18	803	50
H ₂ + ·CF ₂ → Products	5.00E-19	873	51
·CF ₂ + O ₃ → Products	1.39E-19	300	50
·CF ₂ + H· → ·CHF ₂	1.80E-21	673	52
H ₂ + ·CF ₂ → CH ₂ F ₂	4.43E-23	673	52
COF₂ Reactant			
COF ₂ + H· → CHF ₂ O(·)	1.96E+00	600	53
O(1D) + COF ₂ → Products	7.41E-11	298	54
O(1D) + COF ₂ → CO ₂ + F ₂	2.09E-11	298	54
COF ₂ + CO → FCO + FCO	3.83E-14	2200	55
COF ₂ + ·F → CF ₃ O	9.10E-16	484	56
COF ₂ + ·F → FCO + F ₂	2.66E-16	2200	55
COF ₂ → FCO + ·F	9.76E-17	2600	57
COF ₂ + H ₂ → Products	1.31E-17	1900	57
COF ₂ + ·OH → HF + FC(O)O·	8.98E-22	600	53
COF ₂ + H· → FCO + HF	5.29E-25	600	53
COF ₂ + H ₂ O → HF + FC(O)OH	4.33E-25	600	53
COF ₂ + H ₂ O → CF ₂ (OH)2	1.20E-25	600	53
·COF Reactant			
·COF + e/M → Products	σ		5
FCO + O· → Products	9.96E-11	300-2000	15
FCO + H· → CO + HF	4.15E-11	600-1400	37
FCO + FCO → COF ₂ + CO	1.80E-11	295	58
FCO + ·F → COF ₂	5.00E-12	298	59
FCO + ·F → CO + F ₂	4.52E-13	2200	55
FCO + F ₂ → COF ₂ + ·F	4.00E-14	298	59
FCO → CO + ·F	5.98E-16	951	60
FCO + O ₂ → Products	4.00E-16	800	60

Chemical Reaction	Rate Constant		Ref.
	k (cm ³ /molecule s)	T (K)	
·CHF Reactant			
·CHF + e/M → Products	σ		5
·CHF + O· → CO + HF	1.20E+00	298	61
H· + ·CHF → Products	4.90E-10	293	62
·CHF + O· → Products	1.50E-10	295	63
·CHF + N → Products	2.51E-11	295	63
NO + ·CHF → Products	7.04E-12	293	64
O ₂ + ·CHF → Products	5.00E-16	295	63
CF Reactant			
CF + e/M → Products	σ		5
CF + NO ₂ → Products	4.00E-11	294	65
CF + N → CN + ·F	3.90E-11	294	65
CF + O· → CO + ·F	3.90E-11	294	65
CF + NO → Products	2.09E-11	294	66
CF + H· → C + HF	1.91E-11	298	17
CF + O· → Products	1.20E-11	293	43
CF + F ₂ → Products	4.37E-12	300	67
CF + N → Products	3.40E-12	293	43
CF + O ₂ → Products	1.60E-12	294	66
CF + ·F → ·CF ₂	1.00E-13	294	65
H ₂ + CF → Products	1.00E-14	284	66
CO ₂ + CF → Products	1.00E-14	284	66
CF ₄ + CF → Products	1.00E-14	284	66
CF + N ₂ O → Products	1.00E-14	294	65
CF + N ₂ → Products	1.00E-14	294	65
CF + H· → ·CH + ·F	1.11E-24	300	68
CF + ·F → C + F ₂	8.12E-63	300	68

Chemical Reaction	Rate Constant		Ref.
	k (cm ³ /molecule s)	T (K)	
CO₂ Reactant			
CO ₂ + e/M → Products	σ		5
N(² D) + CO ₂ → CO + NO	3.60E-13		69
N(² P) + CO ₂ → Products	3.60E-13		69
CO ₂ + NO → CO + NO ₂	5.00E-15	3000	70
CO ₂ + N → CO + NO	1.07E-15	300	71
CO ₂ → CO + O·	1.42E-18	2620	72
CO ₂ + H· → CO + ·OH	1.40E-29	300	73
CO ₂ + O· → CO ₃	1.22E-49	300	73
CO ₂ + H ₂ → CO + H ₂ O			74
CO Reactant			
CO + e/M → Products	σ		5
O(1D) + CO → CO ₂	8.00E-11	100-2100	75
CO + ·F → FCO	5.50E-13	295	76
CO + ·OH → Products	2.41E-13	200-300	31
CO + ·OH → CO ₂ + H·	1.49E-13	298	77
CO + CF ₃ O → Products	6.84E-14	300	78
CO + CF ₃ O → COF ₂ + FCO	2.01E-15	298	78
CO + O· → CO ₂	4.98E-16	300	79
CO + CF ₃ O → CO ₂ + ·CF ₃	4.00E-16	298	78
CO + OF → CO ₂ + ·F	3.65E-17	550	80
CO + O ₃ → Products	1.00E-21	298	81
CO + F ₂ → FCO + ·F	3.11E-22	273-315	82
CO + O ₃ → CO ₂ + O ₂	4.00E-25	296	83
CO + H· → HCO (**)	1.54E-34	300	84
CO + NO ₂ → CO ₂ + NO	3.63E-35	300	85

(*): the rate constant depends on the electron energy, and has been described by an electron-impact cross section (σ).

(**): The reaction order: 3; the unit of $k(T)$ is cm⁶/molecule² s.

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